

## Ex-Officio Correction

1-1	국가	<b>RO/KR</b>
1-2	국제출원번호	<b>PCT/KR2016/006836</b>
1-3	국제출원일자	<b>27 06월 2016 (27.06.2016)</b>
2-1-1	Location	<b>request/parties/applicants/applicant[1]/addressbook[2]/address/street</b>
2-1-2	Original Content	<b>Jangjeon-dong) #303, MEMSNANO Parts Production Center In Pusan National University , 2-1, Busandaehak-ro 63beon-gil</b>
2-1-3	Corrected Content	<b>(Jangjeon-dong) #303, MEMSNANO Parts Production Center In Pusan National University , 2-1, Busandaehak-ro 63beon-gil</b>
2-1-4	Action	<b>replace</b>
3-1	Signature	<b>(PKCS7 전자서명)</b>
3-2	성명	<b>대한민국 특허청</b>
3-3	일자	<b>30 06월 2016 (30.06.2016)</b>